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- 9. (Amended) The crosslinked resin as claimed in claim 1, characterized in that it additionally comprises at least one photoinitiating agent.
- 12. (Amended) The process for the manufacture of ceramic or of glass as claimed in claim 10, characterized in that the simple metal alkoxides are zirconium alkoxide or titanium alkoxide.
- 13. (Amended) The process for the manufacture of ceramic or of glass as claimed in claim 10, characterized in that it comprises a stage of preparation of complex metal alkoxides from lead carboxylate, zirconium alkoxide and titanium alkoxide.
- 14. (Amended) The process for the manufacture of ceramic or glass patterns at the surface of a substrate as claimed in claim 10/characterized in that:
- exposure to radiation is carried out through a mask, so as to define radiationexposed patterns and non-radiation-exposed patterns;
  - it comprises the dissolution of the non-radiation-exposed patterns in a solvent.
- 16. (Amended) The process for the manufacture of a ceramic or of a glass as claimed in claim 10, characterized in that the substrate is glass.
- 17. (Amended) The process for the manufacture of a ceramic or of a glass as claimed in claim 10, characterized in that the substrate is silicon.
- 18. (Amended) A capacitor, characterized in that it is obtained from the process for the manufacture of a ceramic or of a glass as claimed in claim 10.
- 19. (Amended) A piezoelectric transducer, characterized in that it is obtained from the process for the manufacture of a ceramic or of a glass as claimed in claim 10.
- 20. (Amended) A ferroelectric memory, characterized in that it is obtained from the process for the manufacture of a ceramic or of a glass as claimed in claim 10.

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